## Notice of R ferenc s Cited Application/Control No. 10/621,597 Examiner Ida M Soward Applicant(s)/Patent Under Reexamination LIN, CHI-HUI Page 1 of 1

## **U.S. PATENT DOCUMENTS**

*		Document Number Country Code-Number-Kind Code	Date MM-YYYY	Name	Classification
*	Α	US-2002/0175365	11-2002	HIRAYAMA, TERUO	257/329
*	В	US-5,078,498	01-1992	Kadakia et al.	257/330
*	С	US-2004/0077147	04-2004	Lin, Chi-Hui	438/259
*	D	US-6,583,466	06-2003	Lin et al.	257/314
*	Е	US-6,232,632	05-2001	Liu, Yowjuang W.	257/315
*	F	US-5,281,548	01-1994	Prall, Kirk D.	438/259
	G	US-			
	Н	US-			
	ı	US-			
	J	US-			
	К	US-			
	L	US-			
	М	US-			

## **FOREIGN PATENT DOCUMENTS**

*		Document Number Country Code-Number-Kind Code	Date MM-YYYY	Country	Name	Classification
	N					
	0					
	Р					
	Q					
	R					
	s					
	Т					

## **NON-PATENT DOCUMENTS**

*		Include as applicable: Author, Title Date, Publisher, Edition or Volume, Pertinent Pages)
	U	
	٧	
	W	
	х	

\*A copy of this reference is not being furnished with this Office action. (See MPEP § 707.05(a).) Dates in MM-YYYY format are publication dates. Classifications may be US or foreign.